

Amendments to the Specification

Please replace paragraph [10] with the following amended paragraph [10]:

[10] As shown in Fig. 2, a gate pad 14 of the gate pad portion GP along with a gate line of the picture display part 2 is provided on a lower substrate 1. A gate insulating film 22 and an organic protective film 24 are sequentially entirely coated on the lower substrate 1 to cover the gate pad 14. A gate contact hole 16a is formed by patterning the gate insulating film 22 and the organic protective film 24 to expose a portion of the gate pad 14. A gate protective electrode 20 is formed on the organic protective film 24 to electrically connect the gate pad 14 to the gate protective electrode 20 via the gate contact hole 16a.